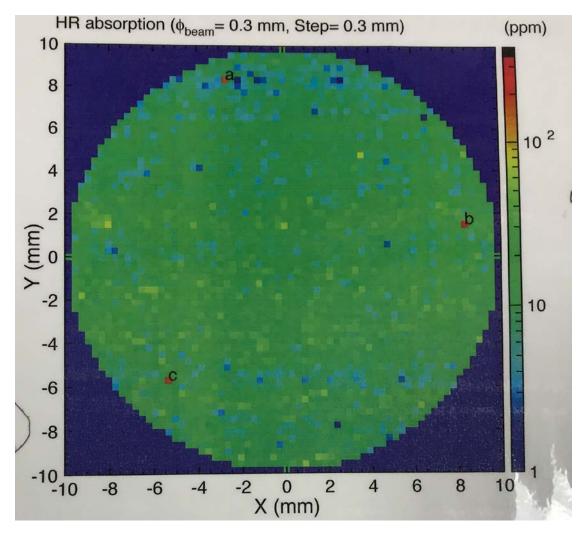
Point absorbers in aLIGO coating

Slawek Gras, Kevin Kuns, and Peter Fritschel

MIT December 2019

Absorption Map: Caltech



DCC: T1900838

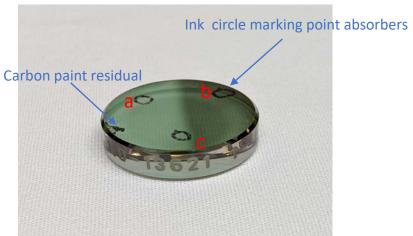
- Witness sample SN#13621 ETM07/09 AR coating
 - material: TiO₂: Ta₂O₅/SiO₂
 - total thickness: \sim 1.6 μm
- 3 high absorption points identified during abortion measurement :

a ~ 180ppm

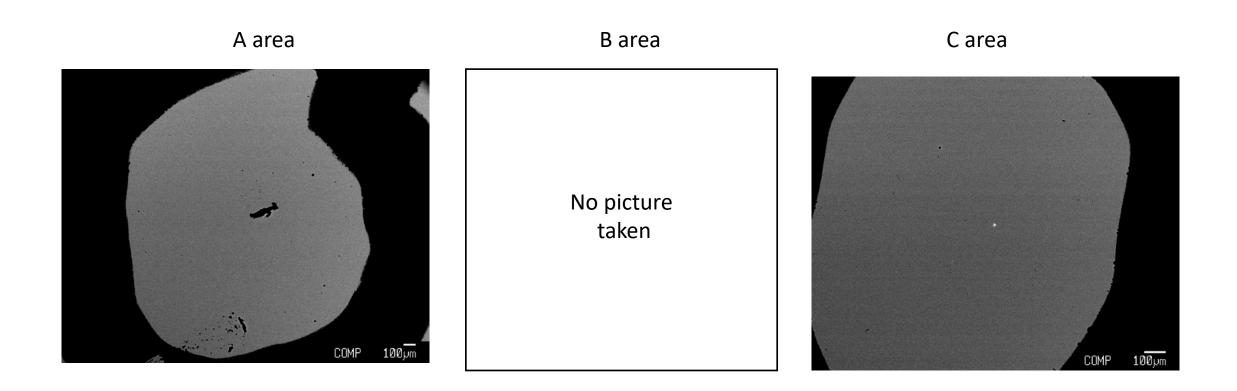
b ~ 270 ppm

c ~ 200 ppm

- The origin of the point absorbers unknown until now
- Many absorber candidates identified from the optical inspection are in fact missing coating.
- SEM/EDS/WDS analysis revealed aluminum is a likely absorber candidate.



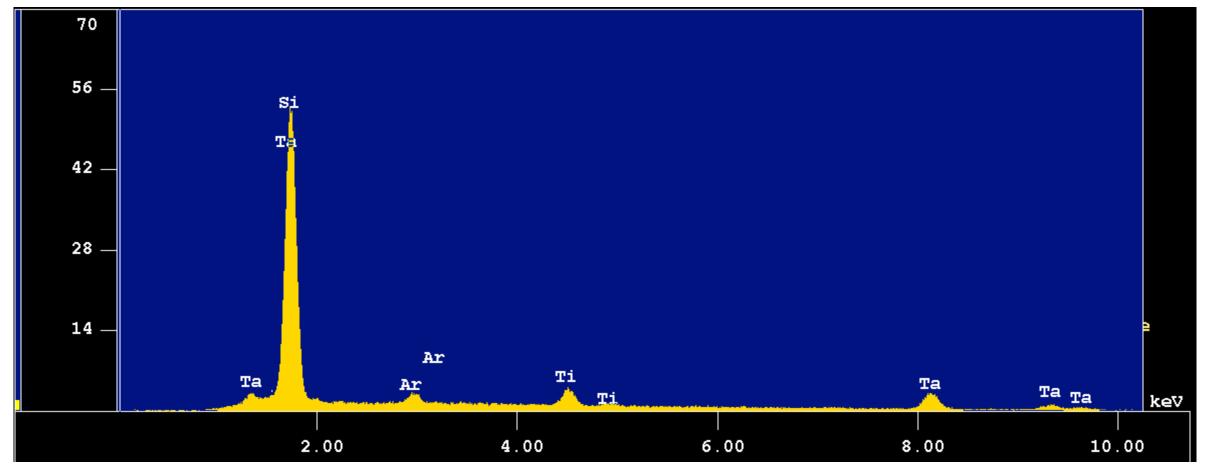
High contrast SEM images



The thick black contours correspond to the ink circles mark areas with high absorption. We left them on the coating.

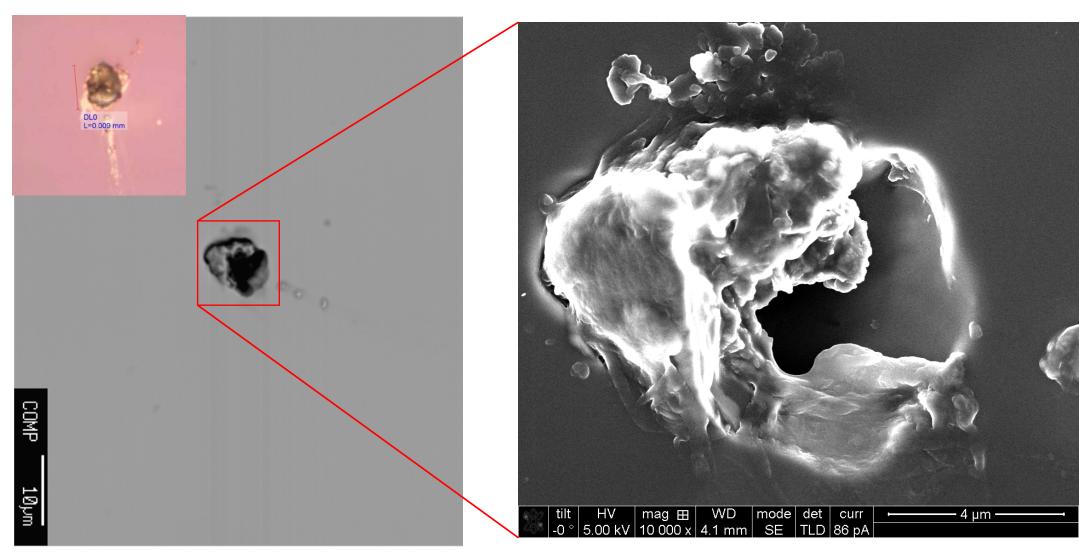
Spectrum of clean coating

From: JEOL JXA-8200, e-beam: 15 kV, 10 nA



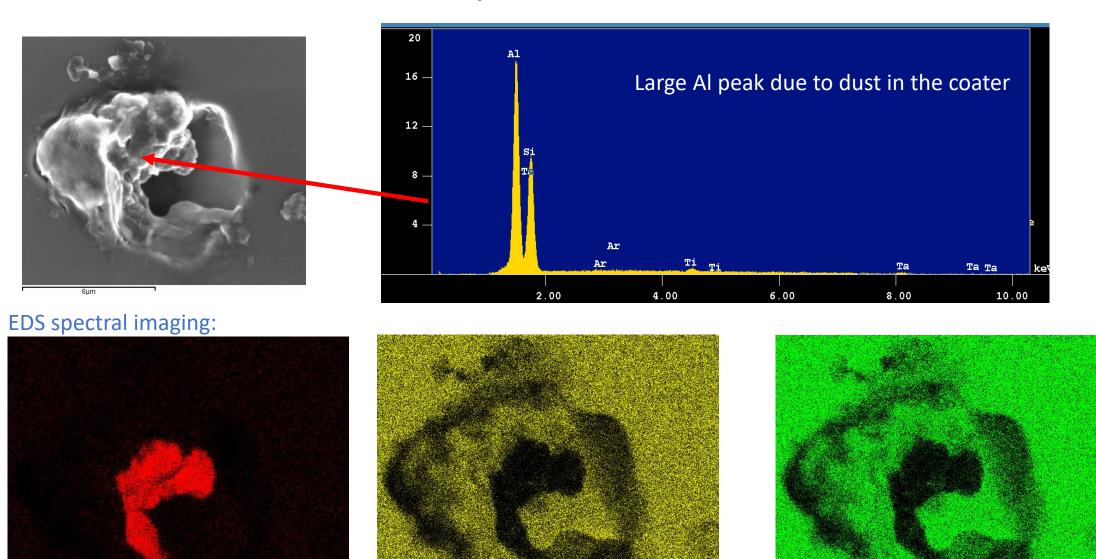
- We see multiple Si, Ta, and Ti lines from the coating
- Trapped Ar lines from IBS plasma
- Oxygen from metal oxides is below 1 keV and too weak to measure with this instrument
- Based on WDS: Ta/Ti = 78.9/21.1

Area B, point absorber B1



Located in Area B. This defect is of \sim 6 μ m in diameter, irregular shape, possibly located in the top layers of the coating

Area B, point absorber B1

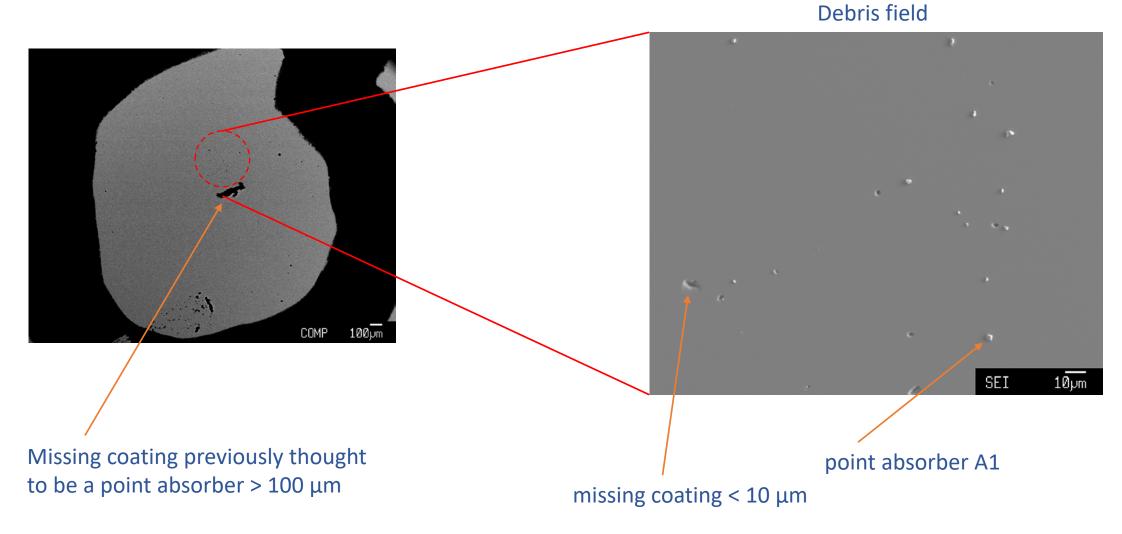


Tantalum

Aluminum

Silicon

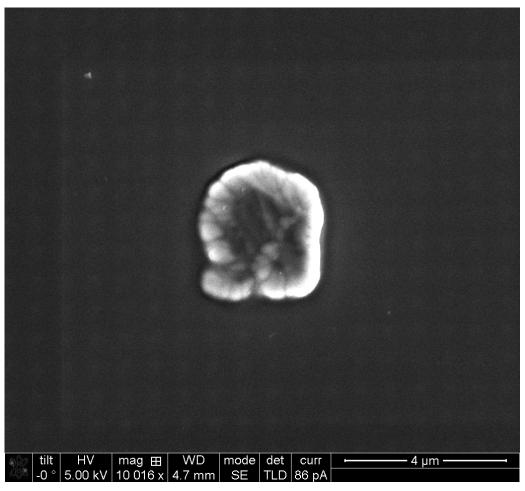
Overview of area A



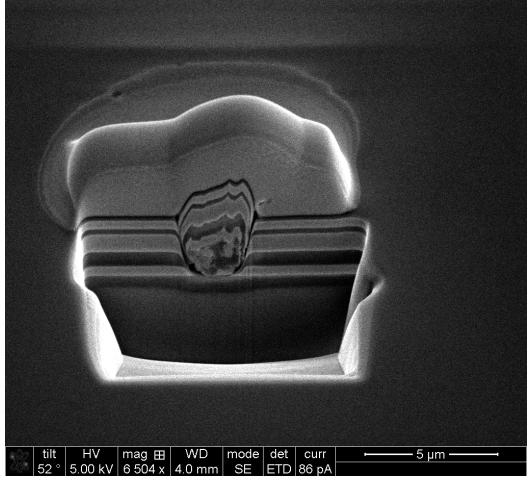
We observe many defects in this field; possible point absorbers, only one inspected so far

Area A, point absorber A1

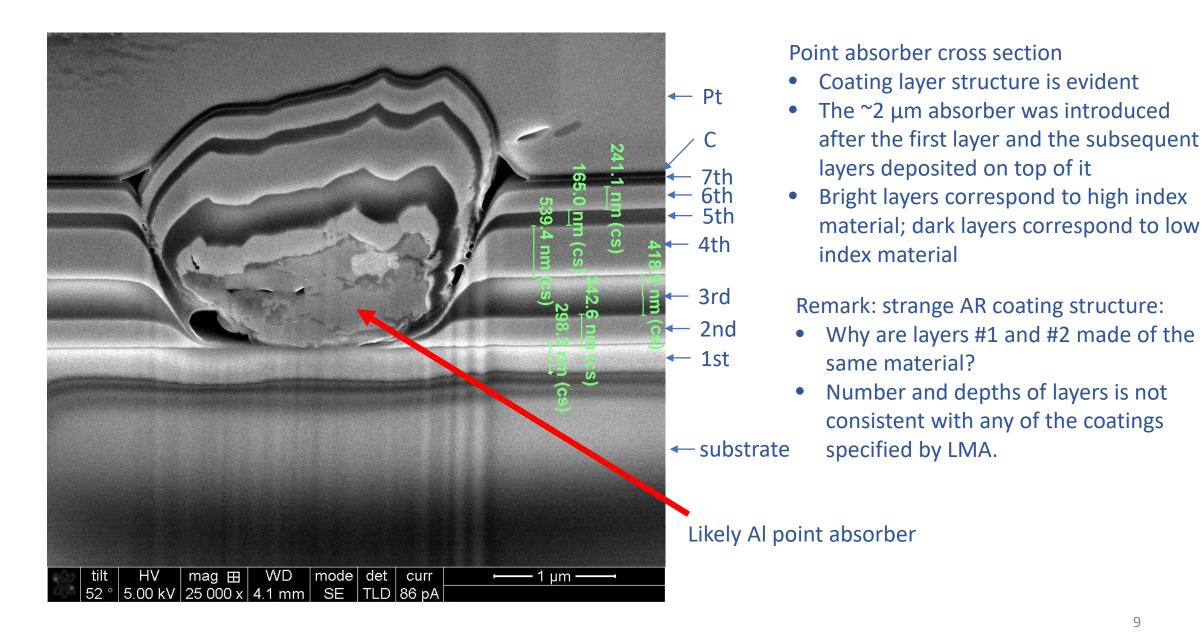
- This defect appears to be part of the coating; it does not look like a particle on the surface
- Spectrum on the surface is the same as that of the clean coating



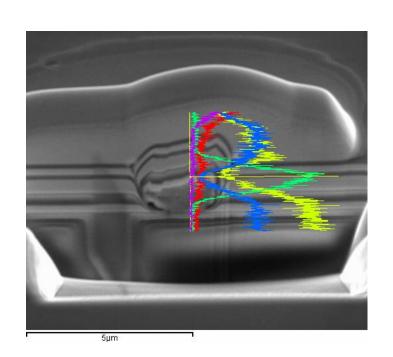
• Used FIB to cut a cross section through the defect:

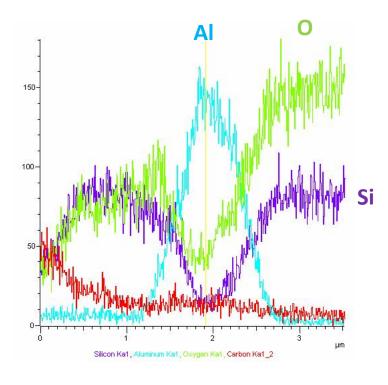


Area A, point absorber A1, cross-section analysis



Area A, point absorber A1, line scan

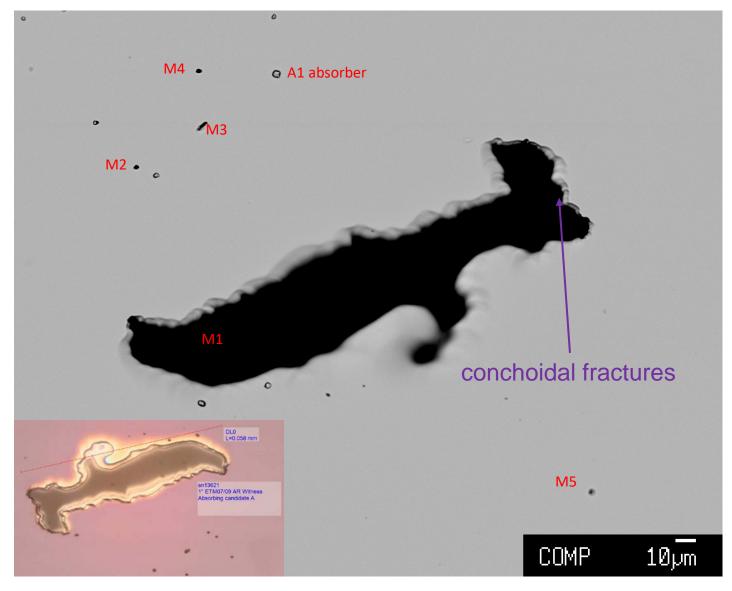




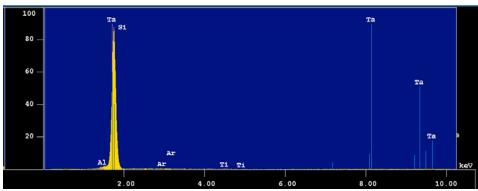
- Strong Al signal at the location of the particle
- Oxygen depletion at the particle location may indicate that we are dealing with pure metal rather than oxide?

There are many more such defects in area A; see slide #7. Are they also caused by Al dust? We are planning to analyze them as well.

Area A, Missing coating

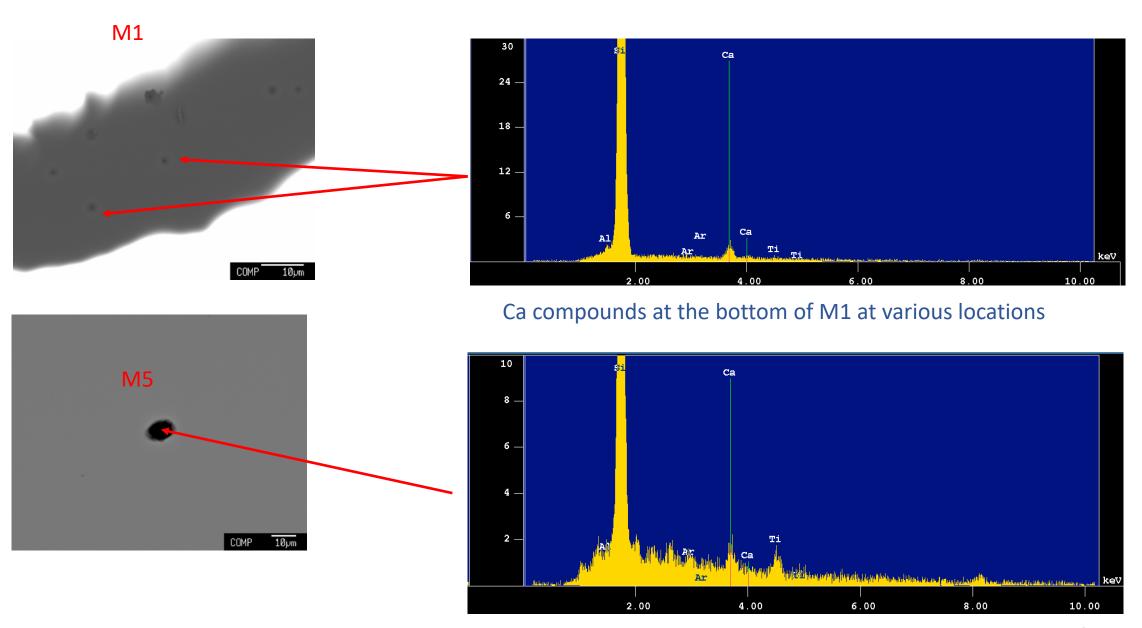


- The missing coating can be easily spotted on large contrast
- 5 places of missing coating with areas of various size, why?
- Conchoidal fractures due to the strain
 burst during annealing process?
- Spectrum at M2, M3, and M4 show only Si above 1 keV – pure substrate, but... see next slide



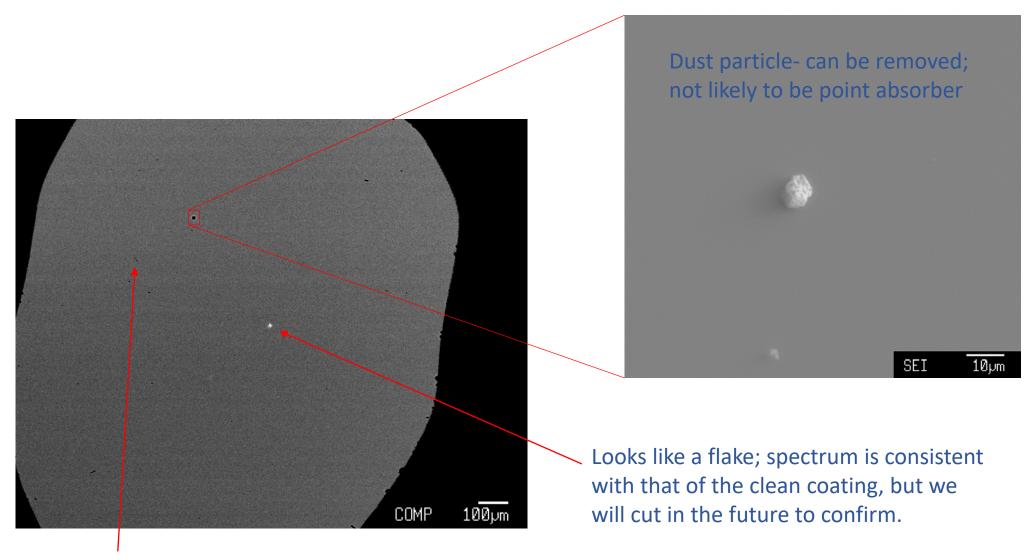
e-beam: 15 kV, 10 nV

Area A, Missing coating, contamination



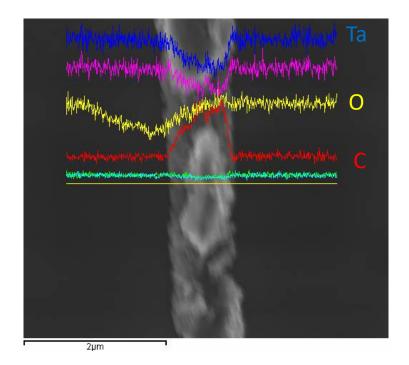
12

Overview of area C



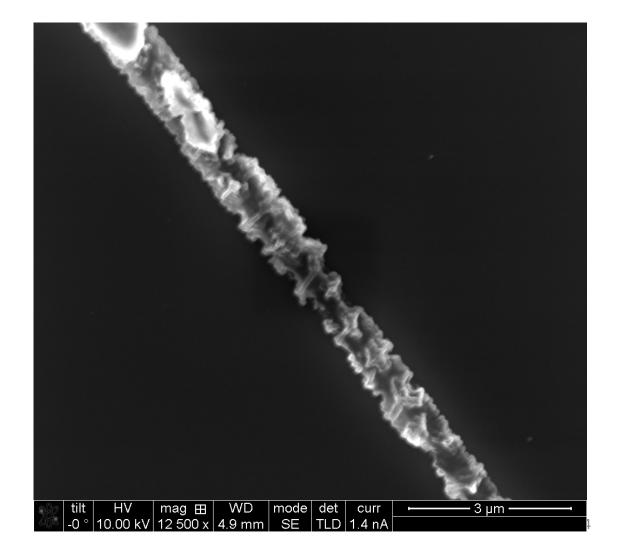
Carbon rod; see next slide

DL0 L=0.021 mm sn13621 1" ETM07/09 AR Witness Absorbing candidate C1



Area C carbon rod

- Absorbing candidate C appears to be a carbon rod
- No evidence of aluminum but we will cut in the future to confirm



Conclusions

- At high absorption locations we found Aluminum particles of size 2-5 μm, most probably metal dust
- Contamination occurs during the coating deposition one defect found near the surface; one found after the first coating layer
- Origin of the Al dust in the coater is unknown at the moment (mask, ion gun components, shredding of the screws, etc. ?)
- Delamination of the coating my be caused by other contaminants (Ca found in the delamination region)
- Planning on cutting remaining features to investigate Al content under the surface
- Will investigate further absorbing candidates near but outside area C

Thank you Dr. Shiahn Chen for SEM piloting assistance.